

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re Patent Application of )  
Koichi KAWAMURA et al. ) Group Art Unit: Unassigned  
Application No.: Unassigned ) Examiner: Unassigned  
Filed: May 23, 2001 )  
For: PHOTORESISTIVE RESIN )  
COMPOSITION )

**PRELIMINARY AMENDMENT**

Assistant Commissioner for Patents  
Washington, D.C. 20231

Sir:

Prior to examination, kindly amend the above-captioned application as follows:

**IN THE CLAIMS:**

Cancel claims 5 and 6 without prejudice or disclaimer.

**IN THE SPECIFICATION:**

Kindly replace the paragraph beginning on page 4, line 20, with the following:

-- Safelight tolerance is a criterion showing the stability of the sensitivity of an image when a printing plate is exposed to a safelight such as a fluorescent lamp and the higher the contrast of the image, the higher is the safelight tolerance. This is concerning with concerns the fact that quinonediazide is partially decomposed by a safelight. This is because if the quinonediazide is a little decomposed by a weak safelight when an image is